Form 1449 (Modified)	Atty Docket No.	NOVLP094/NVLS-2919
	Application No.:	10/789,103
Information Disclosure	Applicant	Wu et al.
Statement By Applicant	Filing Date	February 27, 2004
	Group	1762
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## Foreign Patent or Published Foreign Patent Application

Examiner		Document No.	Publication	Country or	Class	Sub-	<b>Translation</b>	
Initial			Date	Patent Office		Class	Yes	No
	20.	WO 03/052794 A2	26.06.2003	PCT				
	21.	WO 03/005429 A1	16.01.2003	PCT				

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Examiner		
Initial	No.	Author, Title, Place (e.g. Journal) of Publication, Date
	22.	U.S. Office Action mailed November 30, 2006, from U.S Application No. 10/927,777 [Atty Dkt No. NOVLP106/NVLS-2930].

Examiner	Date Considered

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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